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text: Raman spectroscopy can be used to characterize the composion of two-dimensional $Mo_{1-x}W_xS_2$ monolayer alloys $(0 \le x \le 1)$

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ARTICLE TYPE

Composition-Dependent Raman Modes of Mo_{1-x}W_xS₂ Monolayer Alloys

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Two-dimensional (2D) transition-metal dichalcogenide alloys with tunable band gaps have promising applications in nanoelectronics and optoelectronics. Characterization of structures of 2D alloys, such as composition and atom mixing, is of fundamental importance to their applications. Here, we have

¹⁰ conducted systematic Raman spectroscopic studies on $Mo_{1-x}W_xS_2$ monolayers ($0 \le x \le 1$). First-order Raman modes and second-order Raman modes have been observed in the range of 100~480 cm⁻¹ in the 2D alloys. The out-of-plane A'₁ modes and in-plane E' modes showed one-mode and two-mode behaviors, respectively. The broadening of A'₁ and E' modes in the alloys has been observed. The disorder-related Raman peaks at ~360 cm⁻¹ were only observed in the 2D alloys but not in the two end

¹⁵ materials. Modified random-element-isodisplacement (MREI) model has been adopted to successfully predict mode behaviors of A'₁ and E' modes in the monolayer alloys. Further, composition-dependent A'₁ and E' frequencies can be well fitted by MREI model, giving composition-dependent force constants.

Introduction

Two dimensional (2D) materials, such as graphene,¹⁻⁷ BN⁸ and $_{20}$ MoS₂,⁹⁻¹⁴ have attracted extensive interest in recent years due to their unique structures, fundamental physical properties and potential applications. Layered transition-metal dichalcogenides MX₂ (M=Mo, W, Nb, Ta; X=S, Se, Te), a class of materials of covalently bonded layers stacked together by weak van der Waals

- ²⁵ forces,¹⁵⁻¹⁸ are a rich source of 2D crystals. The direct band-gap nature and hence the emergence of strong photoluminescence (PL) in single layer transition-metal dichalcogenides have made them appealing materials for electronic and optoelectronic devices.¹⁹⁻²² Band gap engineering of 2D monolayers is important for those
- ³⁰ applications.^{1,23-27} To achieve band gap tuning in 2D monolayers, alloying transition-metal dichalcogenides has been proposed by theoretical calculations^{28,29} and demonstrated in experiments.³⁰ The key to band gap engineering in monolayer alloys is mixing the end compositions at atomic scale.
- ³⁵ Structure characterization of 2D alloys is challenging. Atomicresolution scanning transmission electron microscopy (STEM) can directly image and discriminate individual atoms.³¹ Raman spectroscopy could also be a powerful tool to characterize structures of 2D alloys. For bulk semiconductors, frequency shift
- ⁴⁰ was used to determine alloy compositions and peak broadening was used to indicate alloy degree.³²⁻³⁴ For 2D materials, Raman spectroscopy has been widely used in characterizations of graphene,^{4,35-38} MoS₂³⁹⁻⁴³ and WS₂.⁴⁴⁻⁴⁷ In this work, we performed a systematic Raman scattering investigation on a series
- ⁴⁵ of Mo_{1-x}W_xS₂ monolayers. The first-order Raman active A'₁ and E' modes and several second-order Raman modes were observed. Polarization dependent Raman scattering measurements were

performed to confirm the assignment of A'₁, E' and second-order Raman modes in $Mo_{1-x}W_xS_2$ monolayers. In $Mo_{1-x}W_xS_2$ ⁵⁰ monolayers, the A'₁ and E' modes showed one-mode and twomode behaviors, respectively. The composition-dependent Raman frequency and full width at half maximum (FWHM) of the dominant Raman modes were discussed. Modified randomelement-isodisplacement (MREI) model has been used to predict ⁵⁵ mode behavior and fit frequency shift in the alloys.

Experimental Section

Sample preparation

 $Mo_{1-x}W_xS_2$ single crystals were grown by the chemical vapor transport method.^{48,49} 2H-type layered structures and alloy compositions for all $Mo_{1-x}W_xS_2$ crystals were confirmed by X-ray diffraction (XRD) and energy dispersive X-Ray spectroscopy (EDX)(Table S1), respectively.⁴⁸ $Mo_{1-x}W_xS_2$ monolayer samples were mechanically exfoliated on Si/SiO₂ (300 nm SiO₂) substrates from bulk $Mo_{1-x}W_xS_2$ single crystals.

65 Characterization

The location, shape and layer number of Mo_{1-x}W_xS₂ flakes were determined by combination of optical contrast and atomic force microscopy (AFM) imaging as shown in our previous work.³⁰ Tapping mode AFM was done on a Vecoo IIIa multimode ⁷⁰ microscope.

Raman and PL measurements were performed on a Renishaw inVia plus under ambient condition at room temperature. The laser excitation was at 514.5 nm (2.41 eV) with a power of ~0.5 mW. The laser spot size was ~1 μ m in diameter. The widely used 75 Porto notations Z(XX) \overline{Z} and Z(XY) \overline{Z} have been used for the designation of crystal and polarization directions⁵⁰ in this work. In the polarized Raman measurements, for $Z(XX) \overline{Z}$ configuration, a polarization analyzer was placed right after the edge filter and the polarization direction was parallel to the s polarization of incident laser beam. The $Z(XY)\overline{Z}$ configuration was conducted by placing a half-wave plate before the analyzer in $Z(XX)\overline{Z}$ configuration.

Results and Discussion

- $Mo_{1-x}W_xS_2$ monolayer flakes were cleaved from the 10 corresponding bulk single crystals onto SiO₂/Si substrates (oxide thickness of 300 nm). Optical imaging and AFM imaging (Figures 1a and 1b) were used to locate and identify $Mo_{1-x}W_xS_2$ monolayers as reported in our previous work.³⁰ Further, compared with $Mo_{1-x}W_xS_2$ few-layers and bulks, $Mo_{1-x}W_xS_2$
- ¹⁵ monolayers showed smaller frequency difference between A'₁ and E' and much stronger PL emission. ^{11,30} Figure 1c shows composition-dependent unpolarized Raman spectra of $Mo_{1-x}W_xS_2$ monolayers with W composition *x* changing from 0 to 1. Taking Mo and W atom as the same and considering the very small
- ²⁰ lattice mismatch between two end component MoS₂ (3.15 Å)⁵¹ and WS₂ (3.153 Å),⁵² the space group of single layer Mo_{1-x}W_xS₂ is expected to be P6m2 (point group D_{3h}). There are totally 9 normal vibration modes at the Γ point in the Brillouin zone for MoS₂ and WS₂ monolayers,^{47,53} in which two accessible first-
- ²⁵ order Raman active modes can be observed in backscattering experiment^{44,54,55} in MoS₂ and WS₂ monolayers: A'₁ and E'. The atomic displacement of Raman modes A'₁ and E' is shown in Figure 1d. The A'₁ mode is an out-of-plane vibration involving only the S atoms while the E' mode associates to in-plane ³⁰ displacement of transition metal Mo or W and S atoms.
- Similar to that of $Mo_{1-x}W_xS_2$ bulk alloys,^{48,49} A'₁ and E' modes of $Mo_{1-x}W_xS_2$ monolayer alloys showed one-mode and two-mode behaviors, respectively. That is, A'₁ mode shifts continuously as the W composition *x*. While two phonon branches associated to E'
- ³⁵ modes of MoS₂ and WS₂ are observed in alloys. As the composition of W increases, the relative intensity of WS₂-like E' mode increases, while that of the MoS₂-like E' mode decreases. The intensities of A'₁ and E' modes of WS₂ monolayer is much stronger than that of other Mo_{1-x}W_xS₂ samples (Figure 1c) due to the term of term of term of the term of te
- $_{40}$ the resonance enhancement (B exciton energy of WS_2 centered at ${\sim}2.36~eV^{30}).$
- In order to confirm the assignments of A'₁, E' modes as well as the second-order Raman features in $Mo_{1-x}W_xS_2$ monolayer alloys, polarization-dependent backscattering experiments have been ⁴⁵ carried out. For D_{3h} point group, the corresponding polarizability
- tensors of the above two first-order Raman modes A^\prime_1 and E^\prime are: 56

$$\alpha (A'_{1}) = \begin{bmatrix} a & 0 & 0 \\ 0 & a & 0 \\ 0 & 0 & b \end{bmatrix},$$

$$\alpha (E') = \begin{bmatrix} 0 & d & 0 \\ d & 0 & 0 \\ 0 & 0 & 0 \end{bmatrix}, \begin{bmatrix} d & 0 & 0 \\ 0 & -d & 0 \\ 0 & 0 & 0 \end{bmatrix}$$
(1)

⁵⁰ Based on polarizability tensor, A'_1 mode should be observed only under $Z(XX)\overline{Z}$ configurations, but not in $Z(XY)\overline{Z}$ configurations. E' mode should be present under both $Z(XX)\overline{Z}$ and $Z(XY)\overline{Z}$ configurations. The Raman peak around 400-420 cm⁻¹ (Figure 2) presented only at $Z(XX)\overline{Z}$ configuration was confirmed to be A'₁. ⁵⁵ The Raman peaks at ~380 cm⁻¹ and 350 cm⁻¹ (Figure 2) presented both under $Z(XX)\overline{Z}$ and $Z(XY)\overline{Z}$ configurations were confirmed to be MoS₂-like and WS₂-like E' modes, respectively.

Note that, for WS₂ monolayer, the lower lying Raman band at \sim 350 cm⁻¹ consists of two components (Z(XY)Z configuration in $_{60}$ Figure 2f): one is assigned to E' mode at \sim 355 cm⁻¹, and the other

- is assigned to 2LA(M) at ~350 cm^{-1.44} In addition, the intensity of 2LA(M) mode in both unpolarized (Figure 1c for *x*=1) and $Z(XX)\overline{Z}$ (Figure 2f) configurations is the strongest one due to a double-resonant Raman process⁴⁴ and dramatically decreases in $(XY)\overline{Z}$ configuration (Figure 2f). The other second-order (SOR) modes (at 263, 295 and 323 cm⁻¹) can be attributed to the combinations of phonons at M point. ^{44,57} The Raman peak at 323 cm⁻¹ is weaker in $Z(XY)\overline{Z}$ configuration than that in $Z(XX)\overline{Z}$ configuration, while the peaks at 263 and 295 cm⁻¹ disappear in
- 70 $Z(XY)\overline{Z}$ configuration.
- For Mo_{1-x}W_xS₂ monolayer alloys with x=0, 0.20 and 0.42 (Figures 2a-c), the asymmetric broad Raman peak at ~450 cm⁻¹ can be assigned to the overlap of a longitudinal acoustic mode 2LA(M) and a normally Raman inactive $A_2^{"}$ optical mode.⁴³ In addition,
- ⁷⁵ the intensity of the Raman peak at ~450 cm⁻¹ decreases obviously in the corresponding Z(XY) \overline{Z} configuration. For Mo_{1-x}W_xS₂ monolayer alloys with *x*=0.20, 0.42, 0.61 and 0.77 (Figures 2b-e), detailed multi-peak curve fittings (as shown in the Figures 2b-e insets) are performed and the assignment of peaks can be carried
- ⁸⁰ out by comparing the locations and polarization dependence with that of the constituent end samples MoS₂ and WS₂.^{43,44} The Raman peak at ~360 cm⁻¹ appearing from x=0.13 to x=0.77 was assigned to an alloy disorder-related peak.^{49,58}
- Figure 3a shows the composition-dependent Raman frequencies so of the different Raman modes in $Mo_{1-x}W_xS_2$ monolayer alloys. With the increasing of W composition, MoS_2 -like E' peak shifts to lower frequency, while WS₂-like E' peak moves slowly towards higher frequency. The A'₁ modes upshift with increasing W composition in monolayer alloys. These variation trends of
- ⁹⁰ Raman frequencies are similar to that of $Mo_{1,x}W_xS_2$ bulk alloys (Figure 4b).⁴⁹ The peak frequency of disorder-related mode at ~360 cm⁻¹ is not sensitive to alloy composition. The peak frequency at ~346 cm⁻¹ (2LA (M) of WS₂) overall shows a decrease trend with decreasing W composition.
- ⁹⁵ Since the monolayer alloys have random distributions of Mo and W atoms without phase separation throughout all W contents.³¹ Mo, W or S atoms should have several different nearest Mo and W coordination configurations in $Mo_{1-x}W_xS_2$ monolayer alloys. This can introduce reduced mass and force constant fluctuation,³²⁻
- ¹⁰⁰ ³⁴ which is responsible for the asymmetric line shapes and peak broadening (see Figure 1c). The variation of FWHM of the firstorder Raman active modes are depicted in Figures 3b and 3c.
- The FWHM of A'₁ mode increases from ~6.2 cm⁻¹ (at x=0) to ~12.9 cm⁻¹ (at x=0.61) and then decreases to ~5.7 cm⁻¹ at x=1 ¹⁰⁵ (Figure 3b). The maximum peak width at intermediate W
- ¹⁰⁵ (Figure 3b). The maximum peak width at intermediate W compositions may indicate disorder-induced broadening. For E' modes (see Figure 3c), as the W composition increases, the FWHM of WS₂-like E' increases first from ~10.8 cm⁻¹ (at x=0.20) to ~13.7 cm⁻¹ (at x=0.42), then decreases to ~4.8 cm⁻¹ at x=1. The

(9)

FWHM of MoS₂-like E' mode almost monotonically increases from ~4 cm⁻¹ (at x=0) to ~11.6 cm⁻¹ (at x=0.88), instead of reaching a maximum peak width at intermediate W composition. This needs further investigation.

- ⁵ MREI model has been successfully used to predict and fit lattice vibrational modes of mixed crystal structures, such as $AB_{1-x}C_x$ type⁵⁹ and $AB_{2-x}C_x$ type.⁶⁰ The MREI model is based on the assumptions of isodisplacement and randomness,⁶¹ i.e., (1) same kind of atoms vibrate in the same amplitude and phase and (2) all
- ¹⁰ substituted atoms are randomly distributed. Previous STEM imaging revealed random distributions of Mo and W atoms, which verifies the 'randomness' assumption.³¹ Based on MREI model for $Mo_{1-x}W_xS_2$ monolayer alloys (Figure 4a), ignoring the S-S interactions, we can write the motion equation for A'₁ mode,

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$$m_s \ddot{\mu}_s = -(1-x)F_1 \mu_s - xF_2 \mu_s \,, \tag{2}$$

where m_s and μ_s are mass and displacement of the S atoms. The terms F_1 and F_2 are force constants representing interactions between S-Mo, S-W along vertical direction, respectively (Figure 4a). Linear changing of force constants on alloy composition is ²⁰ assumed,

$$\frac{F_1}{F_{10}} = \frac{F_2}{F_{20}} = 1 - \theta_1 x \tag{3}$$

where F_{10} and F_{20} are the limiting values of force constants F_1 and F_2 , respectively, as $x \rightarrow 0$. The parameter θ_1 takes into account the variation of force constants.

$$\omega^{2} = \frac{(1-x)(1-\theta_{1}x)F_{10} + x(1-\theta_{1}x)F_{20}}{m_{s}}$$
(4)

²⁵ This predicts one mode behavior for A'₁ mode, consistent with experimental observation.

For E' mode, the motion equations are

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$$m_{s}\ddot{\mu}_{s} = -(1-x)F_{3}(\mu_{s}-\mu_{Mo}) - xF_{4}(\mu_{s}-\mu_{W}) \quad (5)$$

$$m_{Mo}\ddot{\mu}_{Mo} = -2F_3(\mu_{Mo} - \mu_s) - xF_5(\mu_{Mo} - \mu_W)$$
(6)

$$n_W \ddot{\mu}_W = -2F_4(\mu_W - \mu_s) - (1 - x)F_5(\mu_W - \mu_{Mo}) \quad (7)$$

where m_s , m_{Mo} and m_W are the mass of S, Mo and W atoms, ³⁰ respectively. μ_s , μ_{Mo} and μ_W are the displacement of S, Mo and W atoms, respectively. F_3 , F_4 and F_5 are force constants representing interactions between S-Mo, S-W and Mo-W along horizontal direction, respectively (see Figure 4a). Instead of linear changing of force constants on alloy composition which gives a ³⁵ poor fitting for experimental E' data (see Figure S1), quadratic

$$\frac{F_3}{F_{30}} = \frac{F_4}{F_{40}} = \frac{F_5}{F_{50}} = 1 - \theta_2 x - \theta_3 x^2 \tag{8}$$

where F_{30} , F_{40} and F_{50} are the limiting values of force constants F_3 , F_4 and F_5 , respectively, as $x \rightarrow 0$. The parameters θ_2 and θ_3 take into account the variation of force constants.

⁴⁰ Similarly, we can get two eigenvalues (details in supporting information),

$$\omega^2 = \frac{R_1 + R_2 \pm \sqrt{(R_1 - R_2)^2 + 4R_{12}R_{21}}}{2}$$

where

$$R_{1} = \frac{(1-x)F_{3}}{m_{s}} + \frac{2F_{3}}{m_{Mo}} + \frac{xF_{5}}{m_{Mo}}$$

$$R_{2} = \frac{xF_{4}}{m_{s}} + \frac{2F_{4}}{m_{W}} + \frac{(1-x)F_{5}}{m_{W}}$$

$$R_{12} = \frac{xF_{4}}{m_{s}} - \frac{xF_{5}}{m_{Mo}}$$

$$R_{21} = \frac{(1-x)F_{3}}{m_{s}} - \frac{(1-x)F_{5}}{m_{W}}$$

This predicts two-mode behavior for E' mode, also consistent ⁴⁵ with experimental observation. If ignoring weak inter-layer interactions in Mo_{1-x}W_xS₂ bulk alloys, all formulas used in this model are the same for monolayer alloy and bulk alloy.

The Raman active modes (A'_1 and E' for monolayer, and A_{1g} and E_{2g}^1 for bulk) frequency variation with composition is presented ⁵⁰ in Figure 4b. The Raman frequency shift is similar for monolayer and bulk alloys. Least square fitting was used to fit the experimental data using equation (4) and (9). The experimental data can be well fitted, giving similar force parameters for monolayer alloy and bulk alloy (Table 1). Substituting these ⁵⁵ parameters into equation (4), for monolayer samples, we can get equation

$$\omega_{A'_1} = 401.6(0.002x^2 + 0.080x + 1)^{1/2}, \qquad (10)$$

Meanwhile, substituting these parameters into equation (9), we can get relationship between frequency and alloy composition for MoS₂-like and WS₂-like E' modes (see supporting information). ⁶⁰ The composition-dependent Raman shift can be used to

determine the composition in mixed $Mo_{1-x}W_xS_2$ monolayer alloys.

Conclusions

In summary, the Raman spectra of Mo_{1-x}W_xS₂ monolayer alloys were studied with W composition *x* from 0 to 1. The dominant first-order Raman active A'₁, E' and several second-order Raman modes have been observed in the range 100~480 cm⁻¹. A'₁ and E' modes showed one-mode and two-mode behaviors in Mo_{1-x}W_xS₂ monolayer alloys, respectively. The broadening of A'₁ and WS₂like E' modes in the alloys has been observed. The MREI-model was successfully used to predict mode behaviors and fit the composition-dependent Raman frequencies of A'₁ and E' modes. The Raman frequencies of A'₁ and E' modes can be used to quantify Mo/W compositions.

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L.X. and Y.H. conceived and designed the experiments. D.D. and Y.H. synthesized $Mo_{1-x}W_xS_2$ single crystals. Y.C. N.M., Q. F. and M.Z. exfoliated $Mo_{1-x}W_xS_2$ samples and performed optical imaging AEM Paman abarratorizations Y. Z. Y. Z. and P. T.

s imaging, AFM, Raman characterizations. Y. Z. X. Z. and P. T. performed MREI calculations. Y.C. and L.X. co-wrote the manuscript. J. Z. revised the manuscript. All authors discussed the results and commented on the manuscript.

Notes and references

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Figure 1. (a) Optical micrograph of exfoliated $M_{0,47}W_{0.53}S_2$ flake deposited on the 300 nm SiO₂/Si substrate. Monolayer and bilayer regions are indicated by arrows and marked by "1L" and "2L", respectively. (b) AFM image of the $M_{0,47}W_{0.53}S_2$ monolayer (1L) in panel (a). The inset shows the height profile s along the blue dashed line. (c) Raman spectra of $M_{0,4x}W_xS_2$ monolayers with different W composition *x*. The three solid (blue) lines guided by eyes show frequency shift of E' and A'₁ peaks with W composition *x*. (d) The schematics of displacement of atoms for the Raman active E' and A'₁ modes in $M_{0,4x}W_xS_2$ monolayer.



Figure 2. Polarized Raman spectra of $M_{0_{1,x}}W_xS_2$ monolayer alloys in the range 250~480 cm⁻¹ in $Z(XX)\overline{Z}$ and $Z(XY)\overline{Z}$ configurations with different W composition *x* (a) *x*=0; (b) *x*=0.20; (c) *x*=0.42; (d) *x*=0.61; (e) *x*=0.77 and (f) *x*=1. The first-order Raman peaks E', A'₁and several second-order modes are marked by arrows. The insets in (b)-(e) show the detailed linehape fits in the range marked by squares. The solid lines show the experimental curves, while the dashed lines show the fitting results. The arrows in the insets indicate the corresponding fitted peak positions.

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Figure 3. (a) Composition-dependent Raman frequencies and full width at half maximum (FWHM) of A'_1 (b) and E' (c) modes of $Mo_{1,x}W_xS_2$ monolayer alloys.



¹⁰ **Figure 4**. (a) The schematics of force constants used in MREI model. (b) Composition-dependent Raman frequencies of E' and A'₁ (E_{2g}^1 and A_{1g} for bulk) modes in Mo_{1-x}W_xS₂ alloys. The solid and dashed lines are the MREI fits of Mo_{1-x}W_xS₂ monolayers and bulks, respectively and the scattered square and triangle points are the experimental data of Mo_{1-x}W_xS₂ monolayers and bulks.



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Table 1. MREI-model parameters for Mo_{1-x}W_xS₂ monolayer and bulk alloys (*Note: F in*10⁶amu cm⁻²).

Fitted Parameters	$\mathbf{A'_1}(1L)$ or $A_{1g}(bulk)$			E'(1L) or $E^1_{2g}(bulk)$				
	<i>F</i> ₁₀	F ₂₀	θ_1	<i>F</i> ₃₀	F ₄₀	F ₅₀	θ_2	θ_3
Monolayer alloy	2.581	2.684	-0.040	1.773	2.985	15.615	0.474	-0.101
Bulk alloy	2.649	2.458	-0.148	1.756	2.990	15.610	0.488	-0.115